#### Materials Today: Proceedings xxx (xxxx) xxx



Contents lists available at ScienceDirect

## Materials Today: Proceedings

journal homepage: www.elsevier.com/locate/matpr

# Numerical simulation and optimization of p-NiO/n-TiO<sub>2</sub> solar cell system using SCAPS

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#### ARTICLE INFO

Article history: Received 9 March 2020 Received in revised form 26 April 2020 Accepted 29 April 2020 Available online 19 June 2020

Keywords: Nanostructure Science Numerical simulation Solar cell SCAPS Material

#### ABSTRACT

This study illustrates a numerical simulation and optimization of NiO/TiO<sub>2</sub> metal oxide thin film for solar cell applications. Metal oxide-based solar cells have now become a new and low-cost alternative for sunlight harvesting and solar power generation. Different material properties like thickness, temperature, and density of states for conduction and valence band were varied using the SCAPS 1D template. The study examined various window layer material with varied range of 300 K -400 K temperature. Therefore, the thickness are also varied between 2 to 0.05  $\mu$ m and the interface state 1018 to 1021 for absorber and buffer respectively. The objective of this study is to show the numerical annealing effect on the efficiency of nanostructured p-NiO/n-TiO<sub>2</sub> heterojunction solar cells using Solar Cells Capacitance Simulator (SCAPS). As the p-NiO layer reduced at high thickness the electrons and holes have more time to recombine whereby the increase in thickness also presented more than 100% increase in fill factor (FF) with the efficiency that was varied from 0.03 to 0.05. The analyzed result indicates that the thickness increase in Jsc, FF, density, and efficiency is due to more electron holes pairs generated. © 2020 Elsevier Ltd. All rights reserved.

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#### 1. Introduction

Energy is a crucial feature for social-economic growth and development. The goal of energy transformation is to provide access to energy to improve the quality of life and enhance productivity [1]. Currently, electrical energy is widely generated using fossil fuels [2]. However, the continued use of fossil fuels is not environmentally friendly because of the greenhouse gas emission associated with the use of fossil fuels [1]. Access to electricity has a direct link to good health, agriculture activities and plays a major role in the realization of sustainable development goals [2]. As such, countries must consider measures that will ensure uninterrupted power supply.

Several countries still struggle to deliver affordable, efficient and stable electricity [3]. Present statistics reveals that 87% of the 1.5 billion population of people living in Africa are among the world's highest number within developing countries, without access to electricity [4]. This implies that there is an energy deficit that needs to be met to ensure that more people have access to electricity [5]. The energy deficit should also be met without generating electricity through sources that pose a threat to the environment. The use of renewable energy technologies such as solar energy is suitable to meet this demand. Renewable energy such as solar cells has been recognized to be a viable solution to satisfy the energy deficit and also reduce the environmental problems arising from the use of fossil fuels [6]. In several countries, there is a vast amount of sunlight to support electricity generation from solar cells [7]. Solar radiation can be converted to direct current electricity via solar cells [8].

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The appeal of solar cells for the generation of electricity from incident solar radiation has necessitated the conduct of research in different areas [9]. An important area in this regard is the design of solar cells with enhanced physical properties [10]. The physical properties of the solar cell influence their energy generation efficiency. Examples of physical properties of solar cells are density, temperature, and thickness. Simulation has been used for the optimization of the parameters that influence the generation of electricity from solar energy [1].

https://doi.org/10.1016/j.matpr.2020.04.880

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The design of potential photovoltaic (PV) materials aims to address the issues of realizing high energy efficiency, low cost, and stability [9]. The realization of these performance goals should be considered during the doping of semiconductors used in designing solar cells. Suitable semiconductors for designing solar cells with high performance can be realized from the non – conventional doping of layered p–n type material. All the potential alternative photovoltaic (PV) materials, introduced recently, need to address three major issues: high efficiency, low cost, and stability [11]. Non-conventional doping layered type material under transition metal [12]. It has been under extensive research for the last few years due to the great potentiality of fabricating highly efficient solar cells [13].

The paper presents simulation results of NiO/TiO<sub>2</sub> p-n heterojunction solar cells owing to the numerous uncertainty such as defect, thermal or electrical properties mismatches associated with experiment [14]. This is intending to provide a useful guideline for the experimental design of high-performance metal oxide-based solar cells.

#### 2. Numerical simulation

This numerical analysis employed SCAPS (Solar Cell Capacitance Simulator) a software version 3.3.00 originally designed for polycrystalline thin-films, CdTe and CIGS solar cells. The AC and DC electrical measurements which can be simulated on SCAPS include open-circuit voltage (Voc), short circuit current density (Jsc), fill factor (FF%), quantum efficiency (QE%), efficiency percentage, generation and recombination profiles, heterojunction energy band structure, etc. All these measurements can be calculated and obtained in dark and light conditions at different temperatures and illuminations. Up to seven layers can be added to the cell structure in SCAPSs problem setting window while the physical and electronic properties of these layers and contacts should be imported into their specific sections.

SCAPS solves the basic semiconductor equations namely the Poisson's equations for electrons and holes (1); the equations of continuity for electrons and holes (2) and the carrier transport equations for electrons and holes (3) to obtain the J-V performance of each simulated solar cell architectures [15].

$$\frac{d^2\varphi(x)}{dx} = \frac{e}{\varepsilon_0\varepsilon_r}(p(x) - n(x) + N_D - N_A + \rho_p - \rho_n)$$
(1)

where  $\varphi_{,e}$ ,  $\varepsilon_0$ ,  $\varepsilon_r$ ,  $N_D$ ,  $N_A$ ,  $\rho_p$  and  $\rho_n$  are the electrostatic potential, electrical charge, vacuum permittivity, relative permittivity, charged impurities of donor, charged impurities of acceptor, holes distribution and electrons distribution.

$$\frac{dJ_n}{dx} = G - R \tag{2a}$$

$$\frac{dJ_p}{dx} = G - R \tag{2b}$$

where G is the rate of generation and R is the rate of recombination.

$$J_n = D_n \frac{dn}{dx} + \mu_n n d \varnothing / dx \tag{3a}$$

$$J_p = D_p \frac{dp}{dx} + \mu_n p d \varnothing / dx \tag{3b}$$

where  $J_n$  and  $J_n$  are the electron and hole current densities.

#### 2.1. Simulation program SCAPS

SCAPS is a software windows application program developed at the University of Gent with Lab window/CVI of national Instruments [16]. The mentioned software has been made available in 1998 to university researchers in the photovoltaic community after the second PV World Conference in Wien [17]. A solar cell simulation problem is stored in an ACSI file, which can be read and completely edited by the graphical user interface of SCAPS [18]. This program is organized on several pages or windows in other jargon languages whereby the user can set parameters and in which results are shown. The user can set an operating point such as temperature, thickness, voltage, frequency, and illumination as well as an action list of calculation to carry out I-V, C-V, C-f, Q( $\lambda$ ) [19]. The running parameters in each calculation are (v, f, or  $\lambda$ ) varied in the specified range while all other parameters have the value specified in the operating point [20]. Many auxiliary panels can be navigated by the user according to the research material of the study.

As well the user can directly view previously calculated results: I-V, C-V, QE, C-F and also band diagram, electric field carrier densities, partial recombination current. Such results panel is given in Appendix 2, which illustrates the successful result of the previously calculated I-V, C-V, QE, C-F and energy bands after the layers and parameters been added respectively.

#### 3. Methods

The present work includes a numerical simulation of n-TiO<sub>2</sub>/p-NiO solar cell using SCAPS-1D to obtain its J-V parameters like V<sub>oc</sub>, J<sub>sc</sub>, FF%, efficiency% under AM 1.5 G, 100 mW/cm<sup>2</sup> standard illumination. The properties varied for the p and n sections were based on past literature and are provided in Table 1 below. The temperature was varied in the range of 300 K to 400 K; the thickness was varied between 2 and 0.05  $\mu$ m while the interface state density between the n-TiO<sub>2</sub> and p-NiO was also investigated in the range of 10<sup>18</sup> to 10<sup>21</sup>. The simulations were done without introducing additional defects (Fig. 1).

#### 4. Results and discussions

The variation of current, as a function of wavelength for the p-NiO/n-TiO<sub>2</sub> solar cell, is represented in all the J-V curves presented. Thickness is plotted for each experiment simulation using different parameters relative to different layers. Increased in current as the voltage increased indicated that current in the solar cell depends on voltage and carrier transport mechanism. At high voltages, the high current generated is as a result of high numbers of photo-generated carriers and extended absorption into sub-gap photons.

Tal	ble 1
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Material properties	n-TiO <sub>2</sub>	p-NiO
Thickness	2.7-0	2-0.05
Bandgap	2.26	3.0
Electron affinity	4.20	3.25
Relative dielectric permittivity	10.00	7.12
CB effective density of states (1/cm <sup>3</sup> )	2.0E + 17	2.0E + 17
VB effective density of states (1/cm <sup>3</sup> )	6.0E + 17	1.1E + 19
Electron mobility (cm <sup>3</sup> /Vs)	1.0E + 2	2.0E + 2
Hole mobility (cm <sup>3</sup> /Vs)	25.0	9.0E + 1
Shallow uniform donor density N <sub>D</sub> (1/cm <sup>3</sup> )	1.0E + 17	0
Shallow uniform acceptor density $N_D (1/cm^3)$	0	1.0E + 19

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Fig. 1. The set-up of the simulated p-NiO/n-TiO<sub>2</sub> solar cell.

#### 4.1. P-Type thickness variations

Generally, since electron mobility is greater than hole mobility, the p-layer is thicker than n-layer in real-life applications so that an equal number of charge carriers (electrons and holes) could reach the opposite electrodes in almost equal time without getting recombined. The n-layer is usually made smaller so that its width would become less than the diffusion length of holes. Hence, holes in the n-layer can easily diffuse to the metal electrode before recombination occurs. Our simulation covered the variation of the width of both p and n-layer to find the optimum width for the NiO/TiO<sub>2</sub> solar cell system. This optimization further helps to establish why thick absorbers maximize absorption and thin absorbers maximize current collection [21]. For all the thickness varied, the recombination current density remained fairly constant between 1 and 2 mA/cm<sup>2</sup> while the electrons and holes recombined faster as the thickness reduces. The recombination distances obtained were  $3.5 \,\mu$ m,  $2.4 \,\mu$ m,  $1.9 \,\mu$ m,  $1.6 \,\mu$ m,  $1.4 \,\mu$ m for corresponding 2, 1, 0.5, 0.1 and 0.05  $\mu$ m of p-layer thickness varied in this simulation. Therefore, as the thickness of the p-NiO layer reduces, the electrons and holes spend less time to recombine thereby increasing the statistical rate of recombination. Since at higher thickness, the electrons and holes have more time to move before recombining, combined e-h pairs might not lose their energy as heat immediately but can transfer these energies to other existing electrons and holes thereby making the recombination type at high thickness an Auger recombination while those at a lesser thickness of p-layer are non-radiative recombination [22].

The increase in thickness of NiO via the absorbent layer gives room for an increase in the number of photons to be absorbed. From Fig. 2, the Jsc and efficiency increased as the thickness is varied from 0.05 to 2 except for Jsc which decreases from 1 to 2. There was more than 100% increase in Fill Factor (FF) value from 2.5 at 0.05 to 5.21 at 2  $\mu$ m. The efficiencies are given as 0.03; 0.03; 0.03; 0.04; 0.05 for 0.05; 0.1; 0.5; 1; 2  $\mu$ m respectively. This means that the efficiency of the solar cell was not dependent on the thickness of less than 1  $\mu$ m. The increase in Jsc and FF and efficiency is as a result of more electron – holes pairs generated as the thickness increase.

#### 4.2. N-type thickness variations

The n-layer which is always the most doped layer creates a wide depletion region located almost entirely in the p-layer. It is important to note that n-layers should be relatively thin compared to p-type to allow the photons to penetrate the layers without get-ting absorbed much or converted to electron/hole pairs which immediately get separated in the built-in electric field. The recombination profile followed that of the p-layer variation except at the



Fig. 2. Plot of (a) Voc, Jsc, Fill factor and efficiency (b) J-V characteristics of p-NIO/n-TiO<sub>2</sub> solar cell versus thickness of p-layer in microns.

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Fig. 3. Plot of (a) V<sub>oc</sub>, J<sub>sc</sub>, Fill factor and efficiency (b) J-V characteristics of p-NiO/n-TiO<sub>2</sub> solar cell versus thickness of n-layer in microns.



Fig. 4. Plot of (a) Voc, Jsc, Fill factor and efficiency (b) J-V characteristics of p-NiO/n-TiO<sub>2</sub> solar cell versus temperature.

Please cite this article as: R. T. Mouchou, T. C. Jen, O. T. Laseinde et al., Numerical simulation and optimization of p-NiO/n-TiO<sub>2</sub> solar cell system using SCAPS, Materials Today: Proceedings, https://doi.org/10.1016/j.matpr.2020.04.880

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Fig. 5. Plot of (a) Voc, Jsc, Fill factor and efficiency (b) J-V characteristics of p-NiO/n-TiO<sub>2</sub> solar cell versus CB and VB density of states for p-layer.



Fig. 6. Plot of (a) Voc, Jsc, Fill factor and efficiency (b) J-V characteristics of p-NiO/n-TiO<sub>2</sub> solar cell versus CB and VB density of states for n-layer.

0.5, 0.1 and 0.05  $\mu$ m thick n-layer. At those thicknesses, the system shows a non-Langevin type of recombination which is not influenced by the layer thickness, yet a good performance is obtained appendix (Appendix 1).

A thicker buffer layer absorbs energy carried by photon resulting in a higher number of photon loss. The SCAP simulation fitted well with the theory as seen in Fig. 3 below. The Jsc reduced from 0.05 to 1  $\mu$ m; the FF reduced from 0.5 to 2  $\mu$ m, but this does not have a general implication on the efficiency of the solar cell as shown by the Fig. 3 below. The decrease from 1.5 in 0.01 to 1.1 in 0.5  $\mu$ m and from 2.05 in 1 to 0.17 in 2  $\mu$ m is as a result of the fact

that; more thicker buffer layers hastens recombination of holes and is thereby resulting in photon loss and Jsc, FF loss.

An increase in temperature reduces the bandgap of a semiconductor and some other parameters. The open-circuit voltage decreases when temperature increases since it depends on I<sub>o</sub>. The short circuit current, I<sub>sc</sub>, increases slightly with temperature since the bandgap energy  $E_g$  decreases and more photons have enough energy to create e-h pairs. However, this is a small effect and the temperature dependence of the short-circuit current by 0.0006 per°C. The recombination distance was fairly constant through-out all temperature variations within the range of

 $3.5\mu$  m. Generally, the J-V characteristics (Jsc, Voc, FF and n%) are temperature-dependent. Jsc, FF and n % increase with temperature due to reduction in the bandgap energy Voc decrease because it depends directly on the saturation current which in turn decreases within the increase in temperatures. The Jsc of (0.72552, 0.871, 1.0166, 1.12829, and 1.17839); FF of (3.77, 3.84, 4.01, 4.28, and 4.59) and n of (0.03, 0.03, 0.04, 0.04, and 0.05) were obtained for 300, 325, 350, 375, and 400 respectively. The Voc obtained was 0.9275, 0.9158, 0.9037, 0.8995, 0.8793 v for the same order of temperature variations as shown in Fig. 4 below.

A higher density of localized states reduces the separation of the quasi-Fermi level and results in lower  $V_{oc}$  values. The effect of the carrier mobility in relation to the  $V_{oc}$  value is less direct since in open-circuit conditions there is now direct current extraction. The carrier mobility can have an influence in the recombination mechanism, which in open-circuit and steady recombination must equal the generation rate. The  $V_{oc}$  drops because of a higher density of states along with  $J_{sc}$  and FF values owing to the decreased carrier mobility [23]. The optimal value of efficiency depends on the CB & VB density of states (Fig. 5). The higher values of Jsc, FF and n % were obtained at E18. The Jsc and FF decreased fairly on the density of states increase. The density of states does not have a significant effect on the efficiency of the solar cells.

The Jsc and FF decreased as the CB and VB density of states increases in the n-type  $TiO_2$ . A decreasing trend of 1.2187, 1.201, 1.209, and 1.130 was observed in Jsc for E17, E18, E19, E20, E21. All efficiency remained as 0.05 with an increase in CB and VB density of states of n-type  $TiO_2$ . The Voc also increases with a decrease in the CB and VB density of states from 0.846 to 0.8878v for E20 and E 17 (Fig. 6).

5. Conclusion

The above-mentioned example illustrates the numerical simulation program SCAPS is a valuable tool in film solar cells based on NiO/TiO<sub>2</sub> p-n types. This paper was able to give mathematical equation and theoretical optimization of a spin coating NiO/TiO<sub>2</sub> heterojunction solar cell at 300 to 400 K, 2 to 0.05  $\mu$ m and 2 E-17 to 2 E-21 density as the NiO/TiO<sub>2</sub> thin film structured were studied, this solar cell was optimized for different parameters like the thickness of the p-n absorber layer, the temperature and the density that had a strong impact on the efficiency. All Jsc, C-V, FF parameters have been calculated and it was found that the optimized value of the cell thickness varied from 2 to 0.05 for the p-NiO layer and 0 to 2.7 for the n-TiO<sub>2</sub> layer. These results and findings enhance the need to improve and optimized accessibility and sustainable energy that could support further research in thin-film solar cells in affordable and low-income countries.

#### **Declaration of Competing Interest**

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence the work reported in this paper.

#### Acknowledgments

The authors would like to acknowledge and thank the principal author of this SCAPS Software for providing such a veritable tool (simulator program) used in this study. Gratitude goes to the University of Johannesburg South Africa for financial support. Appreciation is also extended to the SCAPS team for allowing the usage of the program. In Acknowledgement, the authors thank the financial support from URC and would also like to thank NRF for financial support.

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Absorption model     alpha (y-0)       imposed     imposed       imposed     imposed       absorption constant A (I/cm eV^*(%))     1.000E+5       absorption constant B (eV**(%)(xm))     0.000E+0   (no metastable configuration possible)	shallow uniform accep	tor density NA (1/cm3)	1.000E+15					
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Appendix 1. Typical data input properties panel of the SCAPS graphical user interface allowing to set the parameters of one particular defect level in one particular layer.

В



Appendix 2: An example of a SCAPS panel displaying calculated results: energy band panel, I-V, and QE.

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